L Number	Hits	Search Text	DB	Time stamp
1	29	madou-marc-jin. modou-min. modou-m-jin.	USPAT;	2004/05/23
		modou-marcin.	US-PGPUB;	13:55
	į		EPO; JPO;	
			DERWENT	, ,
2	9519	430/311,312,313,320,322,323,328,396.ccls.	USPAT;	2004/05/23
	i		US-PGPUB;	13:56
			EPO; JPO;	
	1687	(microfluidic micro-fluidic micro adj fluidic) near2 device	DERWENT	0004/05/00
3	100/	(interonaldic intero-naidic intero adj naidic) nearz device	USPAT; US-PGPUB;	2004/05/23
		•		13:58
			EPO; JPO; DERWENT	
4	20658	(electrochemical electro-chemical electro adj chemical) near2	USPAT;	2004/05/23
4	20030	cell	US-PGPUB;	13:58
		ccn	EPO; JPO;	13.30
			DERWENT	
5	691697	resist photoresist photo-resist photosensitive photo-sensitive	USPAT;	2004/05/23
ð	09109/	(sensitive near (photo light radiation energy))	US-PGPUB;	14:00
		(Somstave near (photo nght radiation energy))	EPO; JPO;	14.00
			DERWENT	
6	34557	(resist photoresist photo-resist photosensitive photo-sensitive	USPAT;	2004/05/23
Ū	34337	(sensitive near (photo light radiation energy))) with negative	US-PGPUB;	14:08
		(Southing Heat (Photo Inght radiation energy))) with negative	EPO; JPO;	14.00
			DERWENT	
7	8	(("4765864") or ("5130263") or ("4900405") or ("4874500")).PN.	USPAT;	2004/05/23
′	_	((4)-04)(0-00)(4)(4-)(4-)	US-PGPUB;	14:07
			EPO; JPO;	14.07
			DERWENT	
8	1	((resist photoresist photo-resist photosensitive photo-sensitive	USPAT;	2004/05/23
		(sensitive near (photo light radiation energy))) with negative) and	US-PGPUB;	14:05
		((("4765864") or ("5130263") or ("4900405") or	EPO; JPO;	- 0
		("4874500")).PN.)	DERWENT	
9	3	(madou-marc-jin. modou-min. modou-m-jin.	USPAT;	2004/05/23
		modou-marcin.) and ((resist photoresist photo-resist	US-PGPUB;	14:12
		photosensitive photo-sensitive (sensitive near (photo light	EPO; JPO;	
		radiation energy))) with negative)	DERWENT	
10	8	430/311,312,313,320,322,323,328,396.ccls. and (((microfluidic	USPAT;	2004/05/23
		micro-fluidic micro adj fluidic) near2 device) ((electrochemical	US-PGPUB;	14:13
		electro-chemical electro adj chemical) near2 cell)) and ((resist	EPO; JPO;	
		photoresist photo-resist photosensitive photo-sensitive (sensitive	DERWENT	
		near (photo light radiation energy))) with negative)		
11	4889427	cavity channel microchannel micro-channel well microwell	USPAT;	2004/05/23
		micro-well chamber	US-PGPUB;	14:14
			EPO; JPO;	
10	1618369	(laminat\$5 cover\$3) with (cover membrane)	DERWENT	0001/07/22
12	1010309	(tammato coveros) with (cover membrane)	USPAT;	2004/05/23
]			US-PGPUB;	14:16
			EPO; JPO; DERWENT	
13	275609	(cavity channel microchannel micro-channel well microwell	USPAT;	2004/05/00
-0	2/3009	micro-well chamber) same ((laminat\$5 cover\$3) with (cover	US-PGPUB;	2004/05/23
	İ	membrane))	EPO; JPO;	14:16
			DERWENT	
14	32931	(resist photoresist photo-resist photosensitive photo-sensitive	USPAT;	2004/05/23
14	J-7J1	(sensitive near (photo light radiation energy))) near2 (first!	US-PGPUB;	14:16
		bottom lower)	EPO; JPO;	17.10
			DERWENT	
15	32011	(resist photoresist photo-resist photosensitive photo-sensitive	USPAT;	2004/05/23
	J_~_1	(sensitive near (photo light radiation energy))) near2 (second!	US-PGPUB;	14:17
		top! upper)	EPO; JPO;	= -
		• •• ′	DERWENT	

17	1346	(cavity channel microchannel micro-channel well microwell	USPAT;	2004/05/23
		micro-well chamber) same ((resist photoresist photo-resist	US-PGPUB;	14:19
		photosensitive photo-sensitive (sensitive near (photo light	EPO; JPO;	
		radiation energy))) near2 (first! bottom lower)) same ((resist	DERWENT	
		photoresist photo-resist photosensitive photo-sensitive (sensitive		
		near (photo light radiation energy))) near2 (second! top! upper))		
16	140	((resist photoresist photo-resist photosensitive photo-sensitive	USPAT;	2004/05/23
		(sensitive near (photo light radiation energy))) with negative)	US-PGPUB;	14:20
		same ((cavity channel microchannel micro-channel well	EPO; JPO;	
		microwell micro-well chamber) same ((laminat\$5 cover\$3) with	DERWENT	
		(cover membrane)))		
18	44		USPAT;	2004/05/23
		micro-well chamber) same ((resist photoresist photo-resist	US-PGPUB;	14:21
		photosensitive photo-sensitive (sensitive near (photo light	EPO; JPO;	
		radiation energy))) near2 (first! bottom lower)) same ((resist	DERWENT	
		photoresist photo-resist photosensitive photo-sensitive (sensitive		
		near (photo light radiation energy))) near2 (second! top! upper))		
		same ((resist photoresist photo-resist photosensitive		
		photo-sensitive (sensitive near (photo light radiation energy)))		
		with negative)		